41-19/CFA 2**31**-60 Harrison

## CONTINUED PROSECUTION APPLICATION (CPA) UNDER 37 C.F.R. § 1.53(d) REQUEST TRANSMITTAL

		•	
Address to:	Attorney Docket No.:	303.573US1	
Assistant Commissioner for Patents	First Named Inventor:	Gurtej Singh Sandhu	
Box CPA	Express Mail No.:	EL584211141US	
Washington, D.C. 20231	Total Pages (if by fax):	0	

This is a request for filing a continuation application under 37 CFR § 1.53(d) of prior application Serial No. 08/636,069, filed on April 22, 1996, entitled METHOD TO REDUCE FIXED CHARGE IN CVD OZONE DEPOSITED FILMS.

The above-identified prior application in which no abandonment of, or termination of, proceedings has occurred, is hereby expressly abandoned as of the filing date of this request for a CPA. Please use all the contents of the prior application file wrapper, including the drawings, as the basic papers for the new application. (37 CFR 1.53(b) must be used for continuation-in-part applications or for applications where the prior application is not to be abandoned.)

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1	Enter the amendment previously filed on _ under 37 CFR 1.116, but unentered, in the prior application.				
2. <u>X</u>	A Preliminary Amendment ( 9 pages) is enclosed.				
3	This a	pplication is filed by fewer than all the inventors named in the prior application, 37 CFR 1.53(d)(4			
	a	<b>DELETE</b> the following inventor(s) named in the prior nonprovisional application:			
	b	The inventor(s) to be deleted are set forth on a separate sheet attached hereto.			

4. \_\_ A new power of attorney is enclosed.

5. \_\_ Information Disclosure Statement is enclosed.

a. \_\_ Form(s) 1449

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b. \_\_ Copies of IDS Citations

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CONTINUED PROSECUTION APPLICATION (CPA) REQUEST TRANSMITTAL Inventors: Gurtej Singh Sandhu et al.
Prior Application No.: 08/636,069

The filing fee is calculated below on the basis of the claims existing in the prior application as amended at 1 and 2 on the previous page:

	No. Filed	No. Extra	Rate	Fee
TOTAL CLAIMS	29 - 20 =	9	x 18 =	\$162.00
INDEPENDENT CLAIMS	12 - 3 =	9	x 78 =	\$702.00
[ ] MULTIPLE DEPENDENT CLAIMS PRESENTED				\$0.00
BASIC FEE				\$690.00
	TOTAL			\$1,554.00

	IOIAL		91,557.00
6. <u> </u>	Small Entity Status:		
	a A small entity statement is enclosed.	•	•
	b A small entity statement was filed in the prior non proper and desired.	provisional application and such	status is still
	c Is no longer claimed.		
7	A check in the amount of \$50.00 is attached to pay the fil	ing fee.	•
8. <u>X</u>	The Commissioner is hereby authorized to charge the 19-0743.	filing fee of \$1,554.00 to Deposit	t Account No.
9. <u>X</u>	A petition for extension of time in the prior application is \$380.00 to pay the extension fee.	enclosed along with a check in th	e amount of
10	Other :		
CCITI	EGMAN, LUNDBERG, WOESSNER & KLUTH, P.A.	By: Daniel 1.1	Clut
P.O. B	ox 2938, Minneapolis, MN 55402 (612-373-6900)	Atty: Daniel J. Kluth Reg. No. 32,146	
Custo	mer Number 21186		

Express Mail" mailing label nur I hereby certify that this paper of 37 C.F.R. 1.10 on the date indica	. See in baing demonited with the I b	nited States Postal Service "Ex CPA, Assistant Commission	Date of Deposit <u>May 2, 2000</u> .  press Mail Post Office to Addressee" service under r for Patents, Washington, D. C. 20231
Todd Bowie	·	The State of the s	<u> </u>
Printed Name		Signature	

## S/N 08/636,069

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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant:

Gurtej Singh Sandhu et al.

Examiner: Matthew Wipple

Serial No.:

08/636,069

Group Art Unit: 2813

Filed:

April 22, 1996

Docket: 303.573US1

Title:

METHOD TO REDUCE FIXED CHARGE IN CVD OZONE DEPOSITED

**FILMS** 

## PRELIMINARY AMENDMENT & RESPONSE

Box CPA Assistant Commissioner for Patents Washington, D.C. 20231

JUL 1 0 2000

Preliminary to the Examination of the present Continuing Prosecution Application, and in response to the Final Office Action mailed on December 2, 1999, in the parent case, please amend the above-identified patent application as follows.

## IN THE CLAIMS

Please delete claims 7/10 without prejudice or disclaimer. Please amend claims 1/, 31/, 42/, 43, 45, 46-48 and 50-53 as follows:

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(Twice amended) A chemical vapor deposition (CVD) process for depositing borophosphosilicate glass films on a substrate surface, the process comprising:

disposing the substrate within a chemical vapor deposition reaction chamber; heating the substrate to a temperature within a range of at least 480°C to about

700°C

introducing a gas volume of SiO<sub>2</sub> precursors into the chamber; admitting a gas volume of ozone into the chamber; admitting a dopant source for phosphorus into the chamber; admitting a dopant source for boron into the chamber; and [illuminating, with a source of high intensity light, the volume of gas located above the substrate surface]

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